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Notice of Allowability	Application No.	Applicant(s)	Applicant(s)	
	10/709,852	LIAO ET AL.	•	
	Examiner	Art Unit		
	Lynne A. Gurley	2812		
The MAILING DATE of this communication appeal All claims being allowable, PROSECUTION ON THE MERITS IS herewith (or previously mailed), a Notice of Allowance (PTOL-85) NOTICE OF ALLOWABILITY IS NOT A GRANT OF PATENT RI of the Office or upon petition by the applicant. See 37 CFR 1.313	(OR REMAINS) CLOSED in to or other appropriate community GHTS. This application is su	this application. If not including it is application. If not including the control is application will be mailed in during the control in the	ded e course. THIS	
1. This communication is responsive to the application filed 6.	<u>/2/04</u> .			
2. The allowed claim(s) is/are 1-8.				
3. The drawings filed on <u>02 June 2004</u> are accepted by the E	xaminer.			
 4. Acknowledgment is made of a claim for foreign priority unally all bloomethall bloomethall	been received. been received in Application	No	ation from the	
Applicant has THREE MONTHS FROM THE "MAILING DATE" noted below. Failure to timely comply will result in ABANDONM THIS THREE-MONTH PERIOD IS NOT EXTENDABLE.		a reply complying with the re	equirements	
5. A SUBSTITUTE OATH OR DECLARATION must be subminFORMAL PATENT APPLICATION (PTO-152) which give			NOTICE OF	
6. CORRECTED DRAWINGS (as "replacement sheets") must (a) including changes required by the Notice of Draftspers 1) hereto or 2) to Paper No./Mail Date (b) including changes required by the attached Examiner's Paper No./Mail Date Identifying indicia such as the application number (see 37 CFR 1. each sheet. Replacement sheet(s) should be labeled as such in the second sheet.	son's Patent Drawing Review S Amendment / Comment or in 84(c)) should be written on the	n the Office action of education decision decision and the drawings in the front (not the	e back) of	
7. DEPOSIT OF and/or INFORMATION about the deposit attached Examiner's comment regarding REQUIREMENT			Note the	
Attachment(s) 1. ☑ Notice of References Cited (PTO-892) 2. ☐ Notice of Draftperson's Patent Drawing Review (PTO-948)	6. Interview Sur	· ·	ΓΟ-152)	
 3.	8), 7. Examiner's A	lail Date mendment/Comment tatement of Reasons for All Lynne A. Gurley Primary Patent Ex TC 2800, Art Unit:	fusley caminer	

Application/Control Number: 10/709,852

Art Unit: 2812

REASONS FOR ALLOWANCE

The following is an examiner's statement of reasons for allowance: The prior art 1. of record fails to teach or to suggest, either alone or in combination, the steps of the method of the claimed invention: depositing a sacrificial layer on the silicon oxide liner; performing a first chemical mechanical polishing (CMP) to polish the sacrificial layer to the top surface of the gate conductor stacks; coating a spin-on-glass (SOG) layer onto the remaining sacrificial layer and onto the exposed top surface of the gate conductor stacks; forming a photoresist pattern on the SOG layer masking the bit line contact area; using the photoresist pattern as a hard mask, etching the SOG layer, the sacrificial layer, and the silicon oxide liner not covered by the photoresist pattern; removing the photoresist pattern leaving the SOG layer, the sacrificial layer, and the silicon oxide liner within the bit line contact area intact; depositing a silicon nitride liner on the SOG layer within the bit line contact area, the partial top surface and side-walls of the gate conductor stacks; depositing a dielectric layer over the silicon nitride liner; performing a second CMP to polish the dielectric layer to stop on the SOG layer; and selectively removing the remaining SOG layer and the sacrificial layer within the bit line contact area to form the bit line contact hole.

Any comments considered necessary by applicant must be submitted no later than the payment of the issue fee and, to avoid processing delays, should preferably accompany the issue fee. Such submissions should be clearly labeled "Comments on Statement of Reasons for Allowance."

Any inquiry concerning this communication or earlier communications from the examiner should be directed to Lynne A. Gurley whose telephone number is 571-272-1670. The examiner can normally be reached on M-F 7:30-4:00.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, John Niebling can be reached on 571-272-1679. The fax phone number for the organization where this application or proceeding is assigned is 703-872-9306.

Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free).

Lynne A. Gurley
Primary Patent Examiner
TC 2800, Art Unit 2812

LG August 21, 2004